

NS6130-12-001476

Quick Facts

Product	:	Hafnium Oxide Evaporation Material
Stock No	:	NS6130-12-001476
Purity	:	99.95%
Molecular Formula	:	HfO ₂
Form	:	Powder

HAFNIUM OXIDE

Evaporation Material

Purity
99.95%

Technical Specification

Molecular Weight	Density	Melting Point	APS
201.49g/mol	9.68g/cc	2821°C	1-3mm

Hafnium oxide evaporation material is a valuable material in the field of microelectronics, where its high dielectric constant and other properties make it a popular choice for use in the production of high-performance electronic components. Use in the semiconductor industry, hafnium oxide evaporation material has also found applications in the production of optical coatings, microelectronic devices and in the development of solid-state batteries.

HfO₂

APS 1-3mm



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20ZICE4589C



19ZAZGO1274G



20ZICE4588M

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CERTIFIED COMPANY

INTELLIGENT MATERIALS PVT LTD
Derabassi
Punjab (140507)
INDIA

+91 9779 550077, 9779238252

NANOSHEL UK LIMITED
Chapel House,
Chapel St Cheshire,
CW12 4AB United Kingdom

+44 (0) 74 105 488, +44 203 137 5187

NANOSHEL LLC
3422 Old Capitol Suit
1305 Wilmington DE - 19808
United States

+1 646 470 4911